AMENDMENTS TO THE CLAIMS

CLAIMS 1-11 (CANCELLED)

- 12. (New) A nail varnish possessing an antimycotic action, comprising:
 - a) 2 to 80% by weight, with respect to the amount of volatile compounds, of at least one 1-hydroxy-2-pyridone of general formula (I)

in which

R1 represents either a straight or branched alkyl group having from 6 to 9 carbon atoms or a cycloalkyl group having from 3 to 6 carbon atoms,

one of the substituents R2 and R4 represents a hydrogen atom and the other represents a

hydrogen atom or a group chosen from the methyl and ethyl groups, and R3 represents a straight or branched alkyl group having 1 or 2 carbon atoms,

in the free form or in the form of a physiologically acceptable salt, as substance possessing an antimycotic action,

b) from 0.1 to 20% by weight, with respect to the amount of volatile compounds, of a promoter of absorption of the active substance chosen from the group comprising urea, ammonium sulfite, esters and salts of thioglycolic acid, allantoin, enzymes and salicylic acid,

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c) 5 to 40% by weight, with respect to the amount of volatile compounds, of a film-forming agent which is soluble in polar solvents, and optionally

- d) a physiologically acceptable solvent, as well as, optionally,
- e) additives acceptable in cosmetology.
- 13. (New) The nail varnish as claimed in claim 12, wherein the active substance possessing an antimycotic action corresponds to the formula (I) in which R2 and R4 are each a hydrogen atom.
- 14. (New) The nail varnish as claimed in claim 12, wherein the active substance possessing an antimycotic action corresponds to the formula (I) in which R1 represents a cycloalkyl group having from 3 to 6 carbon atoms.
- 15. (New) The nail varnish as claimed in claim 14, wherein the active substance possessing an antimycotic action corresponds to the formula (I) in which R1 represents a cyclohexyl group.
- 16. (New) The nail varnish as claimed in claim 12, wherein the active substance possessing an antimycotic action corresponds to the formula (I) in which R1 represents a -CH₂-CH(CH₃)-CH₂-C(CH₃)₃ group.

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17. (New) The nail varnish as claimed in claim 12, wherein the agent which promotes absorption of the active substance is urea.

- 18. (New) The nail varnish as claimed in claim 12, wherein the active substance possessing an antimycotic action represents 10 to 60% by weight with respect to the amount of nonvolatile components.
- 19. (New) The nail varnish as claimed in claim 18, wherein the active substance represents 20 to 40% by weight with respect to the amount of nonvolatile components.
- 20. (New) The nail varnish as claimed in claim 12, wherein the active substance possessing an antimycotic action represents 0.5 to 20% by weight with respect to the amount of the nonvolatile components.
- 21. (New) The nail varnish as claimed in claim 20, wherein the active substance possessing an antimycotic action represents 2 to 15% by weight with respect to the amount of the non volatile components.
- 22. (New) The nail varnish as claimed in claim 12, wherein the film-forming agent is chosen from the group consisting of acrylic/methacrylic copolymers, polymethacrylate/butyl acrylates, acrylic/acrylate copolymers, polyvinyl alcohol, polyvinylpyrrolidones,

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polyvinylpyrrolidone/vinyl acetates and vinylpyrrolidone/dimethylaminoethyl methacrylates.

- 23. (New) The nail varnish as claimed in claim 12, wherein the solvent is composed of a mixture of the solvents having a boiling point of less than 100°C and of solvents having a boiling point of between 100 and 150°C and optionally of a solvent having a boiling point of between 150 and 200°C.
- 24. (New) The nail varnish as claimed in claim 23, wherein the solvent is a hydrophilic system chosen from the group comprising the water/ethanol, water/isopropyl alcohol and water/butanol mixtures.
- 25. (New) The nail varnish as claim in claim 243, wherein the proportion ranges from 10/90 to 30/70.

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